

Get Book

NANOMETER CMOS VLSI DESIGN FOR MANUFACTURING(CHINESE EDITION)



paperback. Condition: New. Paperback. Pub Date :2014-05-01 Pages: 261 Language: Chinese
Publisher: Science Press nanoscale CMOS VLSI design for manufacturability. the contents include: technology trends CMOSVLSI circuit design; semiconductor manufacturing technology; Light disturbances and defects process and device analysis and modeling;; engraved techniques for physical design for manufacturability technologies; measurement. manufacturing defects and defect extraction; modeling and yield improvement of technical defe.

Download PDF Nanometer CMOS VLSI design for manufacturing(Chinese Edition)

- Authored by MEI] Sandip Kundu . [YIN] Aswi.
- Released at -



Filesize: 7.53 MB

Reviews

Extensive guide for ebook enthusiasts. It is definitely basic but surprises in the fifty percent from the pdf. Your life span is going to be change the instant you comprehensive looking over this ebook.

-- **Audie Hettinger**

Merely no words and phrases to spell out. Indeed, it is actually perform, continue to an amazing and interesting literature. I realized this book from my dad and i advised this pdf to find out.

-- **Jerrod Wolff**

This kind of book is almost everything and made me searching in advance plus more. It is actually writer in basic terms instead of hard to understand. You are going to like how the author write this publication.

-- **Charlotte Russel**
